

Mask Automation Workshop

January 2005

7:30	Breakfast	
8:00	ITRS Updates	Scott Hector
10:00	Break	
10:20	Automation Meeting Start	Patricia Gabella
10:30	Mask Automation: Lessons Learned from the Perspective – AMD	<u>E. Christenson/ A. Haskins</u>
11:00	Automation Overview <ul style="list-style-type: none">- Factory Automation Overview- eDiagnostics Group at ISMI- AEC/APC Overview	<u>Brad Van Eck</u>
12:00	Lunch	
12:45	Automation Perspective Mask Factory <ul style="list-style-type: none">- IBM- DuPont Photomask- Intel	<u>Tom Faure</u> <u>Blaine Woodbury</u> <u>Andon Amoura</u>



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14:15	Break	
14:30	Lithography / Wafer Fab Requirements - Freescale - Texas Instruments	Mike Hamilton <u>Bob Bennett</u>
15:30	SEMI P-10 Update	<u>Wes Erck</u>
16:00	Economics of Photomask Manufacturing	<u>Professor Charles Weber</u>
16:30	Break Directions Break out	Patrica Gabella All
17:30	Wrap-up / close	
18:30	Dinner – Zax Pints & Plates Riverside and Barton Springs	

